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Fabrication and Characterization of Epitaxial, Heterostructures and Amorphous Thin Films

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Deadline for manuscript submissions: closed (20 August 2022)

Message from the Guest Editors

Dear Colleagues,

The formation and characterization of thin films are today indispensable technologies for the development of materials' functionality and the discovery of new applications. Our ability to fabricate high-quality films, ranging from single atomic layer thicknesses up to several micrometers, has opened up a whole new industrial sector that is instrumental for building our future society with its ever-increasing demand on advanced services, energy efficiency and sustainability. This Special lssue. "Fabrication and Characterization of Epitaxial Heterostructures and Amorphous Thin Films", will gather frontline research in this cross-disciplinary field, where a basic knowledge and control of physical and chemical deposition mechanisms, paired with advanced measurement methods, are used for a broad spectrum of applications.

Prof. Dr. Anders Hallén Prof. Dr. Mattias Hammar *Guest Editors*









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Message from the Editor-in-Chief

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